



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Tomoyoshi KUSHIDA

Application No.: 09/435,766

Filed: November 8, 1999

For: SEMICONDUCTOR DEVICE Group Art Unit: 2811

Examiner:

S. Loke

Docket No.:

104361

PRELIMINARY AMENDMENT

Director of the U.S. Patent and Trademark Office Washington, D. C. 20231

Sir:

Prior to initial examination, please amend the above-identified application as follows:

IN THE CLAIMS:

Please replace claims 1 and 4 as follows:

(Four Times Amended) A bipolar semiconductor device comprising:

a drain electrode;

a drain region having a first conductive type semiconductor and disposed on

the drain electrode;

a drift region having a second conductive type semiconductor different from

the first conductive type semiconductor of the drain region and disposed on the drain region;

a channel region having the second conductive type semiconductor and

disposed on the drift region;

a gate region surrounding at least a part of the channel region via an insulation

film, the gate region having the first conductive type semiconductor;

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